INFORMATION DISCLOSURE CITATION	ATTY. DOCKET NO. 829-620		SERIAL NO. 10/771,263
	APPLICANT SHIMADA et al		
(Use several sheets if necessary)	FILING DATE February 4, 2004		GROUP 2871

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		4,636,038	1-1987	Kitahara et al.	349	132	
		4,943,838	7-1990	Ukai	257	347	
		5,003,356	3-1991	Wakai et al.	257	390	
		5,045,905	9-1991	Motai et al.	257	352	
		5,072,262	12-1991	Uekita et al.	257	410	
		5,177,588	1-1993	Ii et al.	257	640	
		5,229,644	7-1993	Wakai et al.	257	749	
		5,246,782	9-1993	Kennedy et al.	428	421	
		5,281,546	1-1994	Possin et al.	438	158	
		5,287,208	2-1994	Shimoto et al.	349	123	
		5,294,820	3-1994	Gemma et al.	257	324	
		5,408,345	4-1995	Mitsui et al.	349	42	
		5,411,629	5-1995	Warfield	216	34	
		5,477,359	12-1995	Okazaki	349	130	
		5,486,493	1-1996	Jeng	438	623	
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-3-

#814624 v1 - 829-620.ids/14

INFORMATION DISCLOSURE CITATION	ATTY. DOCKET NO. 829-620	SERIAL NO. 10/771,263
	APPLICANT SHIMADA et al	
(Use several sheets if necessary)	FILING DATE February 4, 2004	GROUP 2871

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814624

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(Use several sheets if necessary)	FILING DATE February 4, 2004	GROUP 2871

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T.R.C	✓	Notice of Final Rejection mailed December 26, 2000 in corresponding JP application No. 10-220219 (JP Patent No. 3247870)
*		Decision on Appeal mailed October 12, 2001 in corresponding JP application No. 10-220219 (JP Patent No. 3247870)
T.R.C	✓	Opposition Proceedings mailed September 13, 2002 in corresponding JP application No. 10-220219 (JP Patent No. 3247870)
*		Decision on Appeal mailed October 23, 2001 in corresponding JP application No. 10-220219 (JP Patent No. 3247870)
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	✓	Decision on Appeal mailed October 23, 2001 in corresponding JP application No. 10-220220 (JP Patent No. 3253589)
*		Notice of Reasons for Rejection mailed March 16, 2004 in corresponding JP application No. 2001-44409, which is a divisional appln. of JP 10-220220
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Form PTO-FB-A820 (Also PTO-1449)

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-5-

INFORMATION DISCLOSURE CITATION	ATTY. DOCKET NO.	SERIAL NO.
	829-620	10/771,263
(Use several sheets if necessary)	APPLICANT SHIMADA et al	
	FILING DATE February 4, 2004	GROUP 2871

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814624

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